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CLAIMS

A method for producing doped boron comprising the steps of:
introducing a boron containing vapor into a reaction vessel;
introducing a dopant vapor into the vessel to provide a mixture of the
dopant vapor and the boron containing vapor; and

heating the mixture to produce doped boron.

- 2. The method of claim l wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 3. The method of claim 1 wherein the dopant vapor is titanium tetrachloride vapor.
- 4. The method of claim 3 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 5. The method of claim 4 wherein the hydrogen and boron trichloride vapor mixture is a roughly stoichiometric mixture.
- 6. A method of claim 1 including the step of exposing the doped boron to magnesium vapor to convert the doped boron to doped magnesium diboride.
- 7. The method of claim 6 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 8. The method of claim 6 wherein the dopant vapor is titanium tetrachloride vapor.

- 9. The method of claim 8 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 10. The method of claim 9 wherein hydrogen and boron trichloride vapor mixture is a roughly stoichiometric mixture.
- 11. A method according to claim 1 including the step of providing in the vessel a fiber substrate for receiving the doped boron as a coating.
- 12. The method of claim 11 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 13. The method of claim 11 wherein the dopant vapor is titanium tetrachloride vapor.
- 14. The method of claim 13 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 15. A superconductor comprising doped magnesium diboride formed by heating a mixture of a boron containing vapor and a dopant vapor to produce doped boron and exposing the doped boron to a magnesium vapor.
- 16. A superconductor according to claim 15 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 17. A superconductor according to claim 15 wherein the dopant vapor is titanium tetrachloride vapor.
- 18. A superconductor according to claim 17 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.

- 19. A superconductor according to claim 18 wherein the hydrogen and boron trichloride vapor mixture is a roughly stoichiometric mixture.
- 20. A superconductor according to claim 15 wherein the doped boron is a coating on a fiber substrate.
- 21. A superconductor according to claim 20 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 22. A superconductor according to claim 20 wherein the dopant vapor is titanium tetrachloride vapor.
- 23. A superconductor according to claim 21 wherein the dopant vapor is titanium tetrachloride vapor.
- 24. A superconductor according to claim 23 wherein the hydrogen and boron trichloride vapor mixture is a roughly stoichiometric mixture.
- 25. A superconductor according to claim 20 wherein the fiber substrate is a silicon carbide substrate.
- 26. A superconductor according to claim 25 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.
- 27. A superconductor according to claim 25 wherein the dopant vapor is titanium tetrachloride vapor.
- 28. A superconductor according to claim 27 wherein the boron containing vapor is a hydrogen and boron trichloride vapor mixture.

- 29. A superconductor according to claim 28 wherein the hydrogen and boron trichloride vapor mixture is a roughly stoichiometric mixture.
- 30. A superconductor comprising a fiber substrate coated with magnesium diboride doped with a titanium compound.
- 31. A superconductor according to claim 30 wherein the fiber substrate is a silicon carbide substrate.